Title: METHOD OF FABRICATING X-RAY MASK AND METHOD OF FABRICATING SEMICONDUCTOR DEVICE WITH X-RAY MASK FABRICATED BY THIS METHOD Inventors: WATANABE et al.

FIG.1

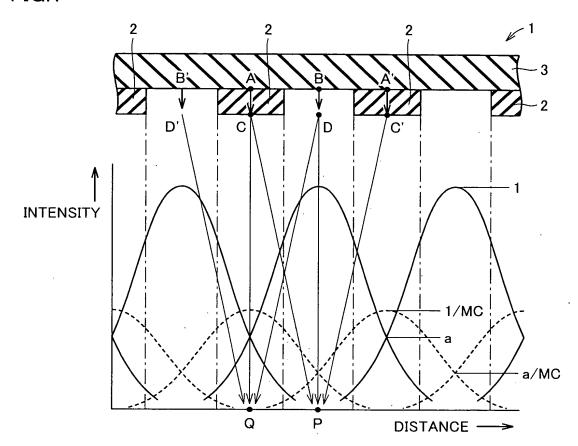
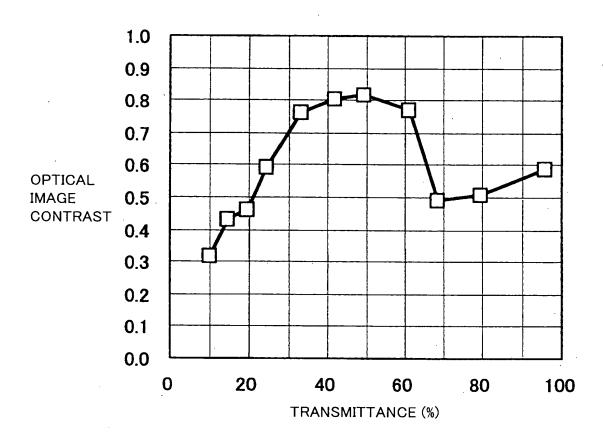
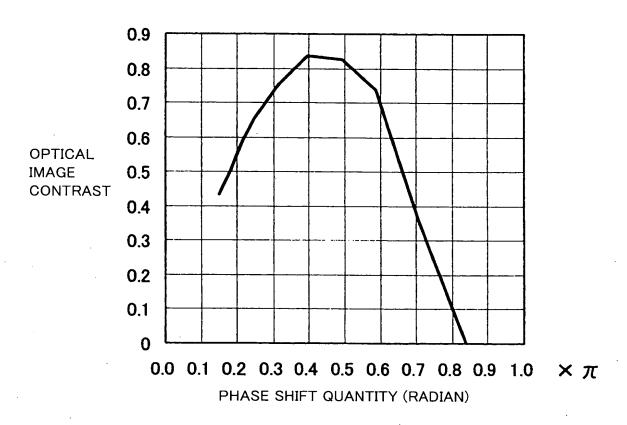


FIG.2

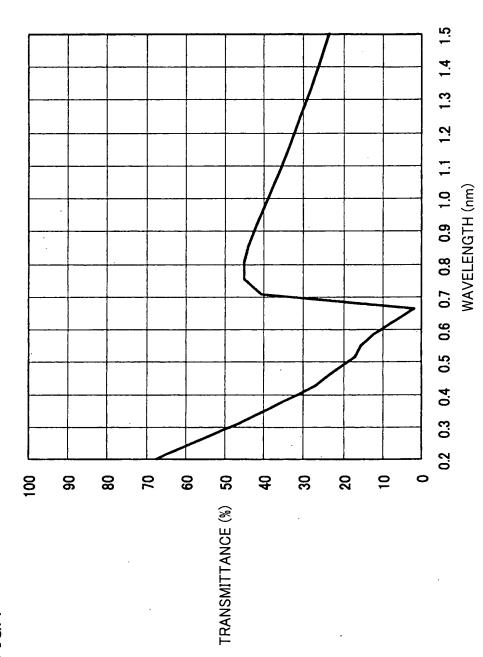


WITH X-RAY MASK FABRICATED BY THIS METHOD
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FIG.3



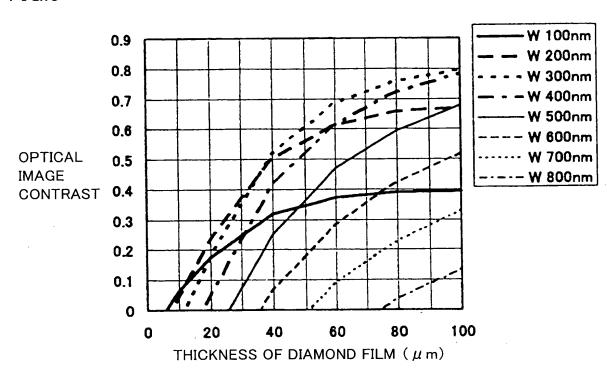
202-737-6770



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FIG.5



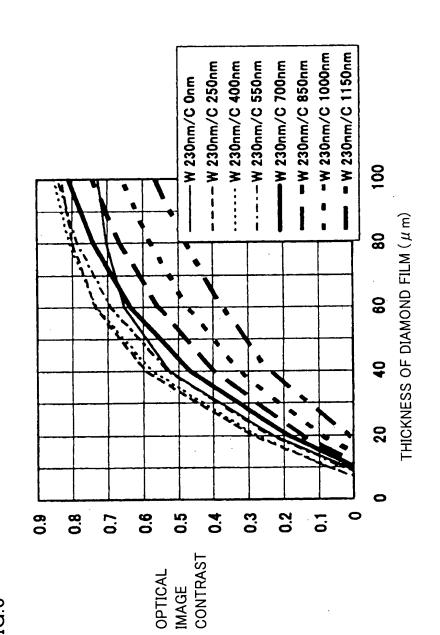


FIG.6

FIG.7

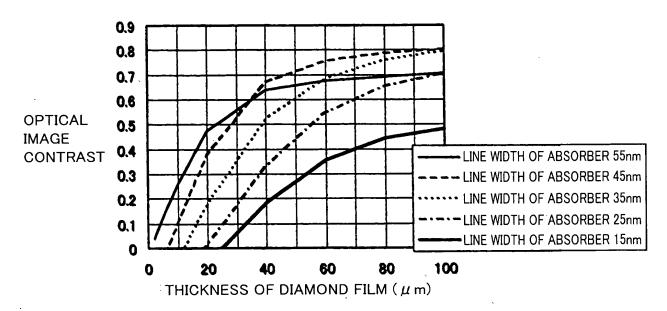
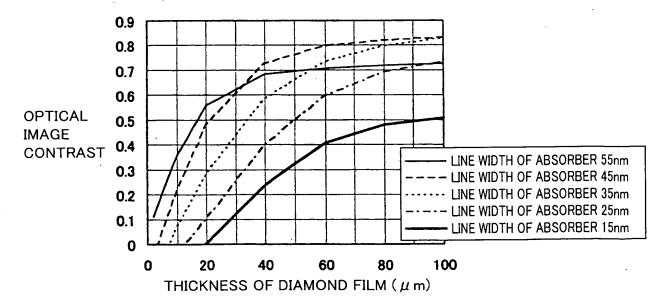
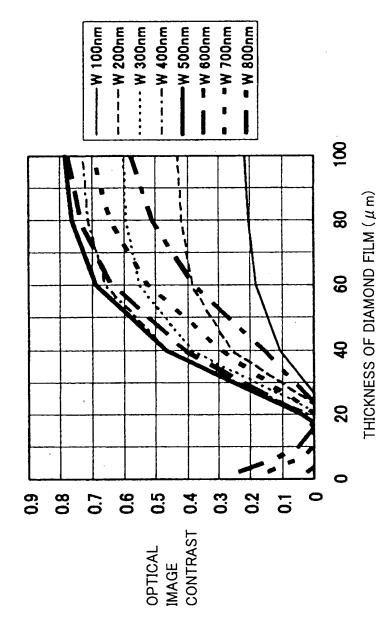


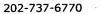
FIG.8



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**-1**G.9



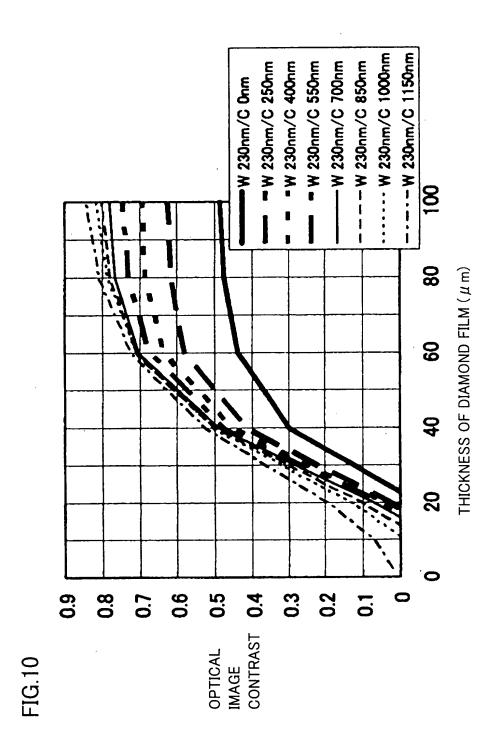


FIG.11

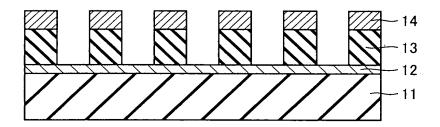


FIG.12

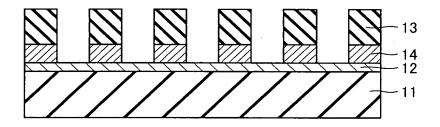


FIG.13

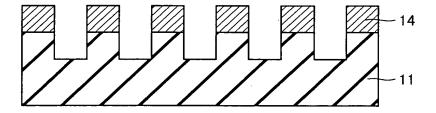


FIG.14

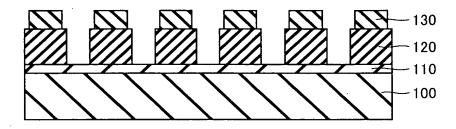
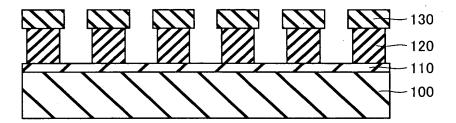


FIG.15



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FIG.16

